

(19) World Intellectual Property Organization
International Bureau



(43) International Publication Date
9 July 2009 (09.07.2009)

PCT

(10) International Publication Number
WO 2009/085751 A1

(51) International Patent Classification:

G03G 15/00 (2006.01) **G03G 21/06** (2006.01)
G03G 15/02 (2006.01)

(21) International Application Number:

PCT/US2008/086982

(22) International Filing Date:

16 December 2008 (16.12.2008)

(25) Filing Language:

English

(26) Publication Language:

English

(30) Priority Data:

61/015,967 21 December 2007 (21.12.2007) US

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(81) Designated States (unless otherwise indicated, for every kind of national protection available): AE, AG, AL, AM, AO, AT, AU, AZ, BA, BB, BG, BH, BR, BW, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DO, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, GT, HN, HR, HU, ID, IL, IN, IS, JP, KE, KG, KM, KN, KP, KR, KZ, LA, LC, LK, LR, LS, LT, LU, LY, MA, MD, ME, MG, MK, MN, MW, MX, MY, MZ, NA, NG, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RS, RU, SC, SD, SE, SG, SK, SL, SM, ST, SV, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, ZA, ZM, ZW.

(84) Designated States (unless otherwise indicated, for every kind of regional protection available): ARIPO (BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European (AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HR, HU, IE, IS, IT, LT, LU, LV, MC, MT, NL, NO, PL, PT, RO, SE, SI, SK, TR), OAPI (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG).

Declarations under Rule 4.17:

— as to applicant's entitlement to apply for and be granted a patent (Rule 4.17(ii))

[Continued on next page]

(54) Title: APPARATUS AND METHODS FOR ALTERING CHARGE ON A DIELECTRIC MATERIAL

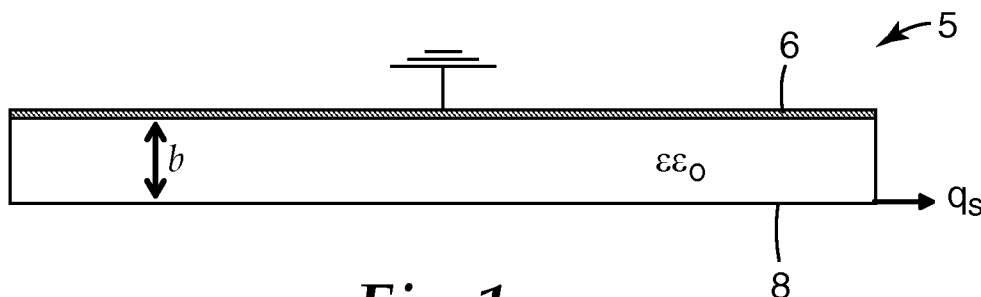


Fig. 1

(57) Abstract: Methods of altering charge on a dielectric material involve application of an at least weakly conductive liquid to at least a portion of the dielectric material. The liquid is then at least partially removed from the dielectric material leaving a substantially uniform electrostatic charge on at least the portion of the dielectric material. Some methods provide a dielectric material that is both net neutral and completely neutral. Other methods generate a charge pattern that is used for subsequent processing.

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— *as to the applicant's entitlement to claim the priority of the
earlier application (Rule 4.17(iii))*

Published:

— *with international search report*